HIGH EFFICIENCY BLUE-GREEN XeF (C → A) LASER*

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Abstract

Blue-green XeF(C) laser output energies in excess of 1 J/l, corresponding to an intrinsic efficiency of ~1.0 per cent have been achieved using e-beam excitation of a unique gas mixture. The relevant parameters which lead to such an efficient broadband blue-green laser are discussed.

Introduction

Recently, significant improvements in the output power and efficiency of the broadband blue-green XeF (C→A) laser have been reported [1,2]. The output power density of the laser has been increased by almost three orders of magnitude, from less than 0.01 J/l to over 1 J/l, corresponding to an intrinsic electrical-optical energy conversion efficiency of about 1%. These results have been obtained as the result of a much better understanding of the important kinetic and optical absorption issues involved with an electron beam excited XeF (C→A) laser medium, and subsequent tailoring of the laser gas mixture for optimum laser performance.

XeF is unique among the rare gas halides, in that the C(\(^{3}P\)) excited state is situated nearly 0.1 eV below the B(\(^{3}P\)) ground state. Thus, the C state contains more than 95% of the excited state population in thermal equilibrium at room temperature. Because the C state decays to the repulsive A state which lies about ~2.5 eV below it, efficient broadband emission in the blue-green is possible. A number of different workers have reported laser emission from XeF in the blue-green. Pumping methods have included electron-beam excitation [3,4], direct electrical discharge excitation [5,6] as well as photolytic pumping of XeF₂ [7,8]. For all of the electrically excited lasers however, the laser energy and efficiency have been very low.

Kinetic models of the energy deposition and reaction channels leading to formation of excited XeF(C) indicate that the process should be very efficient, and that in spite of the low optical gain resulting from the long lifetime and broadband nature of the C→A transition, intense blue-green laser emission should result. However, optical probing of the laser gain medium during and after the electron beam pulse showed that significant broadband absorption, resulting from excited and ionized species within the laser medium, was significantly limiting the output power. In this work, carefully planned changes were made to the laser gas mixture. These additions were specifically designed to control or remove the absorbing species and resulted in significant improvements in the XeF (C→A) laser performance.

Experimental Arrangement

The experimental arrangement used in this work is shown in figure 1. The reaction gases for the XeF (C→A) laser are contained within a stainless steel cell attached to a Physics International Pulserad,110 electron beam machine. A 10 nsec pulse of 1 MeV electrons, with a current density of from 100 to 400 A/cm² is injected through a 50 micron titanium foil, which acts as a pressure barrier between the field emission diode of the e-beam machine, and the gas cell. Dielectric mirrors 2.5 cm in diameter, may be mounted inside the cell to form an optical resonator. The temporal behavior of the emission from the cell is monitored with a fast vacuum photodiode connected to a Tektronix 7912 transient digitizer. Color glass and interference filters in front of the diode determine the spectral range of observation. Time-integrated spectral characteristics are obtained with a PAR OMA-1 optical multichannel analyser. Both the OMA and the transient digitizer are connected to a PDP 11/23 minicomputer for data reduction and compilation. Gain characteristics are obtained with an argon ion laser probe beam which passes through the reaction cell and is then monitored with a fast (less than 1 ns rise time) silicon PIN photodiode. An iris in front of the diode, as well as a narrow-band interference filter limit the fluorescence signal which would otherwise corrupt the gain data. A mechanical shutter in front of the ion laser limits the probe pulse to 4 nsec to avoid saturating the photodiode.

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The stainless steel reaction cell was passivated by prolonged exposure to buffered F\textsubscript{2}, before any experiments were undertaken. High purity gas mixtures of research grade Ar, Xe, Kr, NF\textsubscript{3}, and F\textsubscript{2} were used throughout. Careful monitoring of the exact gas composition for each filling of the cell was done with an MKS Baratron pressure gauge for small percentage constituents, and a precision high pressure gauge for the high pressure buffer gases. A good mix of the constituent gases in the cell was accomplished by turbulent flow of the high pressure buffer gas into the cell during filling. The cell was refilled with a fresh gas mixture after each shot, to avoid depletion and contamination effects.

**Experimental Observations**

Figure 2 shows the e-beam signal, XeF(C→A) fluorescence, optical gain, and laser emission for a typical gas mixture of 8 torr NF\textsubscript{3}, 8 torr F\textsubscript{2}, 16 torr Xe, and 6 atm argon. The optical gain was measured using an argon ion laser probe at 388 nm, which is near the peak of the XeF (C→A) fluorescence emission [9]. Curve A represents the e-beam pulse, as measured with a Faraday cup inserted into the cell. Curve B represents the fluorescence from the XeF(C→A) which begins soon after the onset of the e-beam pulse, reaches a maximum when the e-beam current ceases, and then decays at a rate determined by various quenching processes and the natural lifetime of the excimer. Curve C shows the evolution of the gain/absorption in the laser cavity as a function of time. This curve is typical of the behavior observed for electron beam excited excimer laser media. Beginning with the e-beam pulse there is a rapid build-up of absorption, the result of the creation of various absorbing species in the laser medium. As the XeF(C) state population increases, the net absorption decreases, and finally a net positive gain is observed. Curve D shows that there is a significant delay between the onset of net positive optical gain, and the observation of laser oscillation. This is because with only ~2% net optical gain, the time required for build-up of the optical flux within the cavity is comparable to the duration of the gain. For this reason, even a modest improvement in the net positive gain can have a very significant effect on laser performance.

Recently, we reported that a two halogen donor mixture of NF\textsubscript{3} and F\textsubscript{2} can lead to a significant increase in XeF(C→A) laser performance. Although NF\textsubscript{3} has a good electron attachment coefficient for the electron energies encountered in the e-beam environment of our experiments, it is a poor quencher of potential absorbers such as Xe** (6p and 5d). F\textsubscript{2}, on the other hand, quenches excited states of Xe quite strongly. Therefore, a combination of the two gases can result in good production of XeF while at the same time, provide a removal channel for Xe**, the primary optical absorber in the after-glow of the e-beam pulse [2]. Although F\textsubscript{2} also quenches XeF(C), it, in combination with the NF\textsubscript{3} in the gas mixture, limits the electron density. Electron quenching of XeF(C) can be significant in e-beam excited mixtures. The net result is an increased XeF(C) population over a moderate range of F\textsubscript{2} concentrations.

Figure 3 shows the effect on the laser output of increasing amounts of F\textsubscript{2} added to a mixture of 8 torr NF\textsubscript{3}, 16 torr Xe, and 6 atm of Ar. With up to 8 torr of F\textsubscript{2} added to the mixture, the laser output power increases by almost two orders of magnitude. With concentrations of F\textsubscript{2} greater than 8 torr, the effect of F\textsubscript{2} quenching of XeF becomes apparent, and the laser energy falls off. Varying the NF\textsubscript{3} concentration has a much less pronounced effect on the laser output; however, 8 torr represents an optimum value.
Increasing the Ar buffer gas pressure, or increasing the current density injected into the cell (10 atm max and 400 A/cm² max) results in increased energy output from the laser. A maximum of 1.0 J/l output energy density, with a 5% output coupler was observed. While concentrations of 8 torr F₂, 8 torr NF₃ and 16 torr Xe are true optimum values, the present levels of current density and the buffer gas pressure represent experimental limitations. Indications are that the laser pulse energy density was increasing somewhat faster than linearly with both of these parameters. Although it is difficult to compute the exact energy deposition into the reaction cell, a careful estimation of the overall conversion efficiency for the XeF(C-2A) laser puts the value somewhere between 0.3 and 0.5%, for conversion from the electrical energy deposited in the gas mixture to optical energy coupled out of the cavity.

The effect of the addition of F₂ to the laser gain can be seen in figure 4. Here curve A represents the gain for a 8 torr NF₃ mixture, while curve B represents the gain for a 8 torr NF₃-8 torr F₂ mixture. As is apparent from this figure, the addition of 8 torr F₂ causes a reduction in the initial absorption during the e-beam pulse, and allows the gain to reach a higher maximum value and to last for a longer period of time. Both of these improvements have a very strong effect on the laser output.

![Figure 3. Variation of laser output with F₂ Concentration. Gas mixture laos contains 8 torr NF₃, 16 torr Xe and 6 atm Ar. A 2% output coupler was used in the optical cavity.](image)

![Figure 4. Gain temporal behavior with (A) 8 torr NF₃ and (B) 8 torr NF₃ and 8 torr F₂. Additional gases are 16 torr XE and 6 atm Ar in both cases.](image)

**Discussion**

In recent years, modeling of the kinetic processes leading to the production and quenching of XeF(B,C) has been the subject of considerable investigation [10],[11]. In this work, the results of these studies, as well as some improvements in rate constants have been used in a self-consistent model for the present experimental conditions. Figure 5 shows the primary pathways leading to the formation and quenching of XeF(B,C). The electron beam energy is deposited in the Argon buffer gas, primary electrons, reacting with neutral Ar result in in excited Ar⁺. Secondary electrons can also react with Ar to form Ar⁺ and Ar²⁺. Reaction of these excited argon ion species with xenon result in excited ionic xenon Xe⁺ and Xe²⁺. Subsequent ionic recombination with F⁻ (which was formed by a dissociative attachment reaction between secondary electrons and F₂ or NF₃) results in excited state XeF(B,C). Secondary reactions of Xe with ArF and Ar,F as well as a reaction between F₂ and Xe or Xe⁺ or Xe²⁺ can also result in XeF. The combined production efficiency of the net energy in excited XeF to the total energy deposited in the gas mixture for the present conditions is computed to be about 5-7%. The XeF(B,C) is removed by quenching reactions with Xe, Ar, secondary electrons, and the fluorine donors, as well as by radiative relaxation which gives rise to blue-green photons.

Figure 6 shows the major contributions of the different reactions to the formation of XeF, as well as the relative importance of the various quenching channels which remove XeF. The ionic recombination of F⁻ with Xe produces almost 50% of the total XeF(B,C) population, while quenching by Xe and F₂ are the two most important removal channels.

Although XeF (B,C) is formed with good efficiency, and the state mixing assured by the large Ar pressure means that almost all of the XeF will be relaxed to the C state, the overall laser efficiency is severely limited by photodissociation effects. Figure 7 shows the measured optical absorption at 488 nm for a mixture of 6 atm Ar and 16 torr Xe, as well as that for pure argon. The data shown in this figure was repeated for various lines of the Ar⁺ ion laser, and the results were essentially identical from a wavelength of 457.9 nm to 489 nm [2]. Thus, we conclude that the absorption effects seen here are broad-banded in nature, and extend uniformly across the gain region of interest for XeF(C-2A).
With only argon in the cell, a strong absorption (exceeding 9% cm\(^{-1}\)) is observed, with two decay rates. One time constant is about 15 nsec, while the second, associated with a less pronounced absorption, is about 50 nsec long. Figure 6 (a) shows the calculated excited species concentrations which result from e-beam excitation of Ar. From these results, and published data on the absorption cross section in the blue-green region [12-14] suggest that the strong initial absorption is due to the combined effects of Ar\(_3\) and Ar (4p\(_\text{and} 3d\)) while the longer decay-time absorption is due to Ar\(_2\). Figure 8 (b) shows the computed fractional contribution of each of these species to the total absorption as a function of time.

When Xe is added to the Ar, the initial absorption is decreased, but a much longer-lived absorption, with a time constant of about 300 nsec appears. The reduction in the initial absorption is the result of charge transfer to the Xe, and are thus rapidly quenched. Of the various Xe products which are produced, analysis shows that only Xe (6p, 5d) have a large enough absorption cross section to contribute significantly to the blue-green absorption coefficient [2]. Figure 9(a) shows the temporal evolution of the excited species in an Ar-Xe mixture, while Figure 9(b) shows the relative importance of these to the temporal evolution of the absorption.
With the addition of $F_2$ and $NF_3$ to the gas mixture of Ar and Xe, the $Xe^{**}$'s are also quenched, and so the absorption does not last for as long a time. Most of the quenching of the $Xe^{**}$ comes from reaction with $F_2$, however. $F_2$ has the added advantage that it retains a large electron capture cross-section, even down to electron energies as low as 0.1 eV. Thus, with $F_2$ in the gas mixture, the density of low energy electrons can be significantly reduced. This lowers the electron quenching of $XeF(C)$, and increases the excited state population density, another factor which improves the laser gain. Figure 10 shows the computed absorption as a function of time for a mixture of 8 torr $NF_3$, 8 torr $F_2$, 16 torr Xe, and 6 atm Ar, and the contribution from each of the important absorbing species.

![Figure 10. Computed optical absorption at 488 nm as a function of time for an e-beam excited mixture of 8 torr $NF_3$, 8 torr $F_2$, 16 torr Xe and 6 atm Ar.](image)

![Figure 9. (a) Temporal evolution of important absorbing species in an e-beam excited mixture of 16 torr Xe in 6 atm Ar. (b) Computed relative contribution of absorbing species as a function of time.](image)

Figure 11 depicts the computed gain resulting from the $XeF(C)$ state, as obtained from the product of the calculated $XeF(C)$ population density and the stimulated emission cross-section. The net gain, calculated by taking the difference between the $XeF(C)$ gain, and the absorption (figure 10) is also shown. Figure 11 also depicts the laser intensity build-up in the cavity, calculated from the gain evolution with time. Agreement, both qualitative and quantitative with the observed experimental behavior of the e-beam excited $XeF(C$ $\rightarrow$ $A)$ laser is excellent.

**Summary**

In summary, we have shown that the primary factor limiting the performance of the electron-beam excited $XeF(C$ $\rightarrow$ $A)$ lasers is the presence of broad-band absorbing species created during and after the electron beam pulse. By selection of an appropriate gas mixture - notably one which contains two different fluorine donors, $NF_3$ and $F_2$ - we are able to obtain a good formation rate for $XeF(C)$, and at the same time significantly reduce the effect of absorbers. Levels of output power and conversion efficiency have been achieved which make this laser potentially useful for a number of different applications. Computer simulations show that if the initial absorption could be reduced further, and that if the pumping mechanism could provide an active medium for a longer time, much greater improvements in laser performance could be expected.
Figure 11. Computed temporal evolution of the net gain, XeF(C) population and intercavity optical flux for the conditions of Figure 10.

References